

International IR Rectifier

REPETITIVE AVALANCHE AND dv/dt RATED HEXFET® TRANSISTOR

IRHM9160 IRHM93160 P-CHANNEL RAD HARD

-100 Volt, 0.073Ω, RAD HARD HEXFET

International Rectifier's P-Channel RAD HARD technology HEXFETs demonstrate excellent threshold voltage stability and breakdown voltage stability at total radiation doses as high as 3×10^5 Rads (Si). Under **identical** pre- and post-radiation test conditions, International Rectifier's P-Channel RAD HARD HEXFETs retain **identical** electrical specifications up to 1×10^5 Rads (Si) total dose. No compensation in gate drive circuitry is required. These devices are also capable of surviving transient ionization pulses as high as 1×10^{12} Rads (Si)/Sec, and return to normal operation within a few microseconds. Single Event Effect (SEE) testing of International Rectifier P-Channel RAD HARD HEXFETs has demonstrated virtual immunity to SEE failure. Since the P-Channel RAD HARD process utilizes International Rectifier's patented HEXFET technology, the user can expect the highest quality and reliability in the industry.

P-Channel RAD HARD HEXFET transistors also feature all of the well-established advantages of MOSFETs, such as voltage control, very fast switching, ease of paralleling and temperature stability of the electrical parameters. They are well-suited for applications such as switching power supplies, motor controls, inverters, choppers, audio amplifiers and high-energy pulse circuits in space and weapons environments.

Absolute Maximum Ratings

| | Parameter | IRHM9160, IRHM93160 | Units |
|--|---------------------------------|--|-------|
| I_D @ $V_{GS} = -12V, T_C = 25^\circ C$ | Continuous Drain Current | -35* | A |
| I_D @ $V_{GS} = -12V, T_C = 100^\circ C$ | Continuous Drain Current | -22 | |
| I_{DM} | Pulsed Drain Current ① | -140 | |
| P_D @ $T_C = 25^\circ C$ | Max. Power Dissipation | 250 | W |
| | Linear Derating Factor | 2.0 | W/K ⑤ |
| V_{GS} | Gate-to-Source Voltage | ± 20 | V |
| EAS | Single Pulse Avalanche Energy ② | 500 | mJ |
| I_{AR} | Avalanche Current ① | -35* | A |
| EAR | Repetitive Avalanche Energy ① | 25 | mJ |
| dv/dt | Peak Diode Recovery dv/dt ③ | -16 | V/ns |
| T_J | Operating Junction | -55 to 150 | °C |
| T_{STG} | Storage Temperature Range | | |
| | Lead Temperature | 300 (0.063 in. (1.6mm) from case for 10s | |
| | Weight | 9.3 (typical) | g |

Product Summary

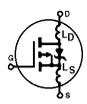
| Part Number | BV_{DSS} | $R_{DS(on)}$ | I_D |
|-------------|------------|--------------|-------|
| IRHM9160 | -100V | 0.073Ω | -35*A |
| IRHM93160 | -100V | 0.073Ω | -35*A |

Features:

- Radiation Hardened up to 3×10^5 Rads (Si)
- Single Event Burnout (SEB) Hardened
- Single Event Gate Rupture (SEGR) Hardened
- Gamma Dot (Flash X-Ray) Hardened
- Neutron Tolerant
- Identical Pre- and Post-Electrical Test Conditions
- Repetitive Avalanche Rating
- Dynamic dv/dt Rating
- Simple Drive Requirements
- Ease of Paralleling
- Hermetically Sealed
- Electrically Isolated
- Ceramic Eyelets

Pre-Radiation

Electrical Characteristics @ T_j = 25°C (Unless Otherwise Specified)

| | Parameter | Min | Typ | Max | Units | Test Conditions |
|------------------------|--|------|-------|-------|-------|---|
| BVDSS | Drain-to-Source Breakdown Voltage | -100 | — | — | V | V _{GS} = 0 V, I _D = -1.0mA |
| ΔBVDSS/ΔT _J | Temperature Coefficient of Breakdown Voltage | — | -0.11 | — | V/°C | Reference to 25°C, I _D = -1.0mA |
| RDS(on) | Static Drain-to-Source On-State Resistance | — | — | 0.073 | Ω | V _{GS} = -12V, I _D = -22A ④ |
| | | — | — | 0.075 | | V _{GS} = -12V, I _D = -35A |
| VGS(th) | Gate Threshold Voltage | -2.0 | — | -4.0 | V | V _{DS} = V _{GS} , I _D = -1.0mA |
| gfs | Forward Transconductance | 15 | — | — | S (τ) | V _{DS} > -15V, I _{DS} = -22A ④ |
| IDSS | Zero Gate Voltage Drain Current | — | — | -25 | μA | V _{DS} = 0.8 x Max Rating, V _{GS} = 0V |
| | | — | — | -250 | | V _{DS} = 0.8 x Max Rating V _{GS} = 0V, T _J = 125°C |
| IGSS | Gate-to-Source Leakage Forward | — | — | -100 | nA | V _{GS} = -20 V |
| IGSS | Gate-to-Source Leakage Reverse | — | — | 100 | | V _{GS} = 20V |
| Qg | Total Gate Charge | — | — | 290 | nC | V _{GS} = -12V, I _D = -35A |
| Qgs | Gate-to-Source Charge | — | — | 52 | | V _{DS} = Max Rating x 0.5 |
| Qgd | Gate-to-Drain ('Miller') Charge | — | — | 90 | | |
| td(on) | Turn-On Delay Time | — | — | 35 | ns | V _{DD} = -50V, I _D = -35A, R _G = 2.35Ω |
| tr | Rise Time | — | — | 170 | | |
| td(off) | Turn-Off Delay Time | — | — | 190 | | |
| tf | Fall Time | — | — | 190 | | |
| LD | Internal Drain Inductance | — | 8.7 | — | nH | <p>Measured from drain lead, 6mm (0.25 in) from package to center of die.</p> <p>Modified MOSFET symbol showing the internal inductances.</p>  |
| LS | Internal Source Inductance | — | 8.7 | — | | |
| Ciss | Input Capacitance | — | 6000 | — | pF | V _{GS} = 0V, V _{DS} = -25 V f = 1.0MHz |
| Coss | Output Capacitance | — | 1400 | — | | |
| Crss | Reverse Transfer Capacitance | — | 400 | — | | |

Source-Drain Diode Ratings and Characteristics

| | Parameter | Min | Typ | Max | Units | Test Conditions |
|-----------------|--|--|-----|------|-------|---|
| I _S | Continuous Source Current (Body Diode) | — | — | -35 | A | Modified MOSFET symbol showing the integral reverse p-n junction rectifier.  |
| I _{SM} | Pulse Source Current (Body Diode) ① | — | — | -140 | | |
| VSD | Diode Forward Voltage | — | — | -3.3 | V | T _J = 25°C, I _S = -35A, V _{GS} = 0V ④ |
| t _{rr} | Reverse Recovery Time | — | — | 300 | ns | T _J = 25°C, I _F = -35A, di/dt ≤ -100A/μs |
| QRR | Reverse Recovery Charge | — | — | 2.1 | μC | V _{DD} ≤ -50V ④ |
| t _{on} | Forward Turn-On Time | Intrinsic turn-on time is negligible. Turn-on speed is substantially controlled by L _S + L _D . | | | | |

Thermal Resistance

| | Parameter | Min | Typ | Max | Units | Test Conditions |
|-------------------|---------------------|-----|------|------|-------|----------------------|
| R _{thJC} | Junction-to-Case | — | — | 0.50 | K/W ⑤ | Typical socket mount |
| R _{thCS} | Case-to-Sink | — | 0.21 | — | | |
| R _{thJA} | Junction-to-Ambient | — | — | 48 | | |

* Current is limited by pin diameter (Die current is 40A , see page 6)

Radiation Performance of P-Channel Rad Hard HEXFETs

International Rectifier Radiation Hardened HEXFETs are tested to verify their hardness capability. The hardness assurance program at International Rectifier uses two radiation environments.

Every manufacturing lot is tested in a low dose rate (total dose) environment per MIL-STD-750, test method 1019. International Rectifier has imposed a standard gate voltage of -12 volts per note 6 and a V_{DS} bias condition equal to 80% of the device rated voltage per note 7. Pre- and post-radiation limits of the devices irradiated to 1 x 10⁵ Rads (Si) are identical and are presented in Table 1. The values in Table 1 will be met for either of the two low dose rate test circuits that are used. Both pre- and post-radiation performance are tested and specified using the same

drive circuitry and test conditions in order to provide a direct comparison. It should be noted that at a radiation level of 1 x 10⁵ Rads (Si) no changes in limits are specified in DC parameters.

High dose rate testing may be done on a special request basis using a dose rate up to 1 x 10¹² Rads (Si)/Sec.

International Rectifier radiation hardened P-Channel HEXFETs are considered to be neutron-tolerant, as stated in MIL-PRF-19500 Group D. International Rectifier radiation hardened P-Channel HEXFETs have been characterized in heavy ion Single Event Effects (SEE) environments and the results are shown in Table 3.

Table 1. Low Dose Rate ⑥ ⑦

| | Parameter | IRHM9160 | | IRHM93160 | | Units | Test Conditions ⑩ |
|----------------------|---|----------------|-------|----------------|-------|-------|--|
| | | 100K Rads (Si) | | 300K Rads (Si) | | | |
| | | Min | Max | Min | Max | | |
| BV _{DSS} | Drain-to-Source Breakdown Voltage | -100 | — | -100 | — | V | V _{GS} = 0V, I _D = -1.0mA |
| V _{GS(th)} | Gate Threshold Voltage ④ | -2.0 | -4.0 | -2.0 | -5.0 | | V _{GS} = V _{DS} , I _D = -1.0mA |
| I _{GSS} | Gate-to-Source Leakage Forward | — | -100 | — | -100 | nA | V _{GS} = -20V |
| I _{GSS} | Gate-to-Source Leakage Reverse | — | 100 | — | 100 | | V _{GS} = 20V |
| I _{DSS} | Zero Gate Voltage Drain Current | — | -25 | — | -25 | µA | V _{DS} =0.8 x Max Rating, V _{GS} =0V |
| R _{DS(on)1} | Static Drain-to-Source ④ On-State Resistance One | — | 0.073 | — | 0.073 | Ω | V _{GS} = -12V, I _D = -22A |
| V _{SD} | Diode Forward Voltage ④ | — | -3.3 | — | -3.3 | V | T _C = 25°C, I _S = -35A, V _{GS} = 0V |

Table 2. High Dose Rate ⑧

| | Parameter | 10 ¹¹ Rads (Si)/sec | | | 10 ¹² Rads (Si)/sec | | | Units | Test Conditions |
|------------------|-------------------------|--------------------------------|------|-----|--------------------------------|------|-----|--------|--|
| | | Min | Typ | Max | Min | Typ | Max | | |
| V _{DSS} | Drain-to-Source Voltage | — | — | -80 | — | — | -80 | V | Applied drain-to-source voltage during gamma-dot |
| I _{pp} | | — | -100 | — | — | -100 | — | A | Peak radiation induced photo-current |
| di/dt | | — | -800 | — | — | -160 | — | A/µsec | Rate of rise of photo-current |
| L ₁ | | 0.1 | — | — | 0.5 | — | — | µH | Circuit inductance required to limit di/dt |

Table 3. Single Event Effects ⑨

| Parameter | Typical | Units | Ion | LET (Si) (MeV/mg/cm ²) | Fluence (ions/cm ²) | Range (µm) | V _{DS} Bias (V) | V _{GS} Bias (V) |
|-------------------|---------|-------|-----|---------------------------------------|------------------------------------|---------------|-----------------------------|-----------------------------|
| BV _{DSS} | -100 | V | Ni | 28 | 1 x 10 ⁵ | ~41 | -100 | 5 |

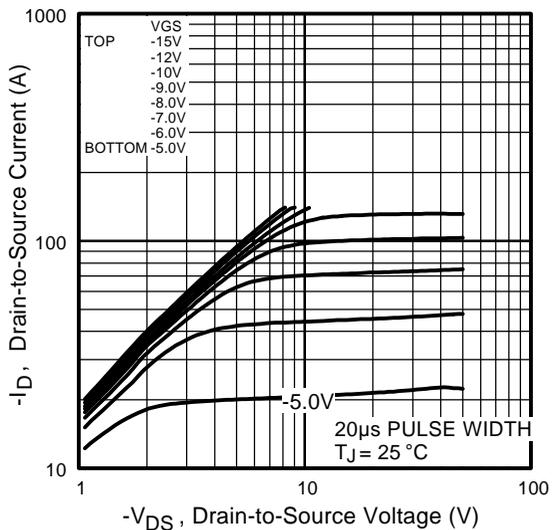


Fig 1. Typical Output Characteristics

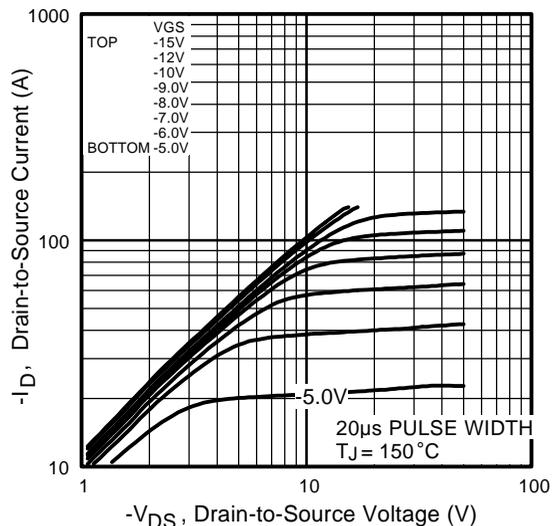


Fig 2. Typical Output Characteristics

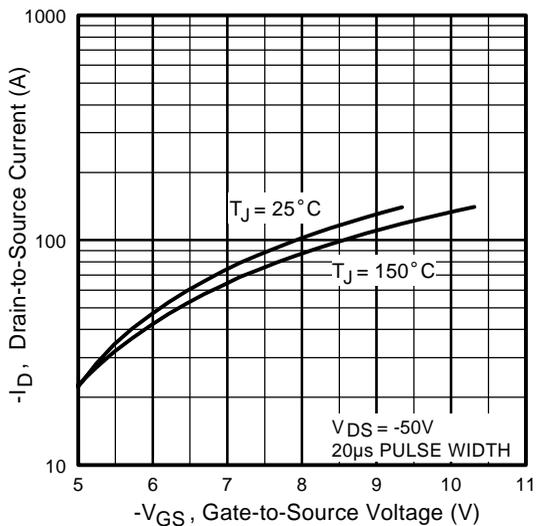


Fig 3. Typical Transfer Characteristics

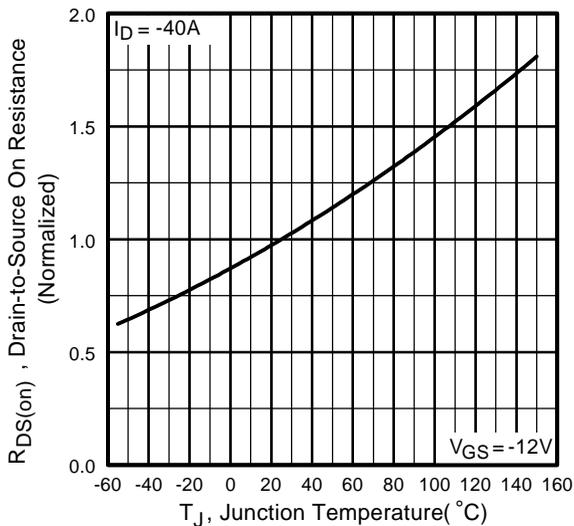


Fig 4. Normalized On-Resistance Vs. Temperature

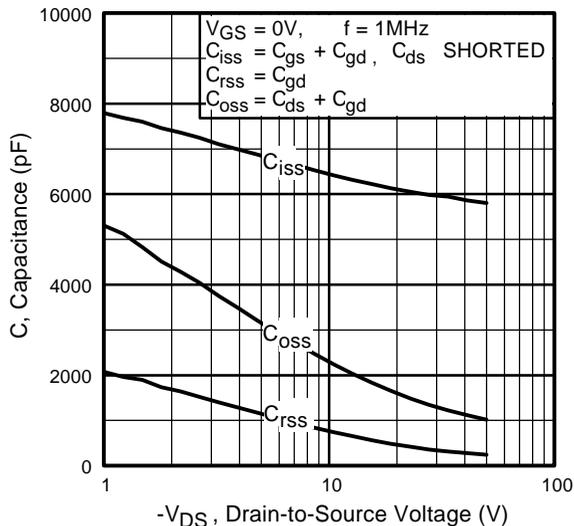


Fig 5. Typical Capacitance Vs. Drain-to-Source Voltage

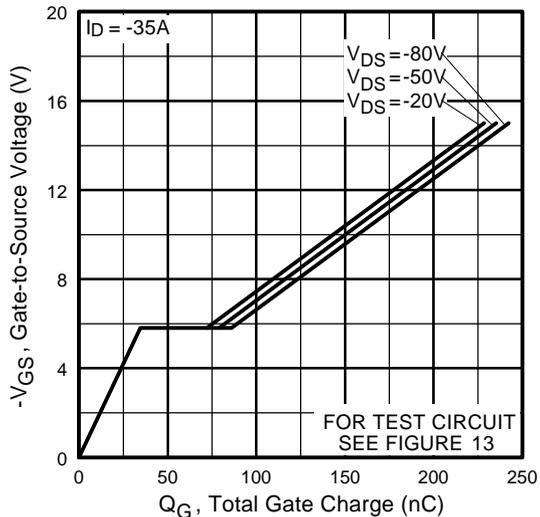


Fig 6. Typical Gate Charge Vs. Gate-to-Source Voltage

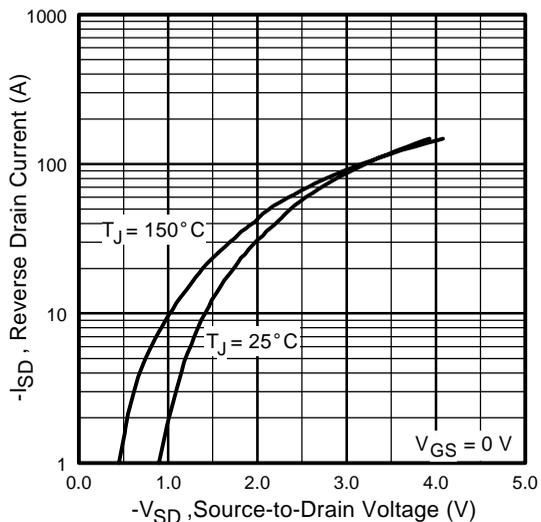


Fig 7. Typical Source-Drain Diode Forward Voltage

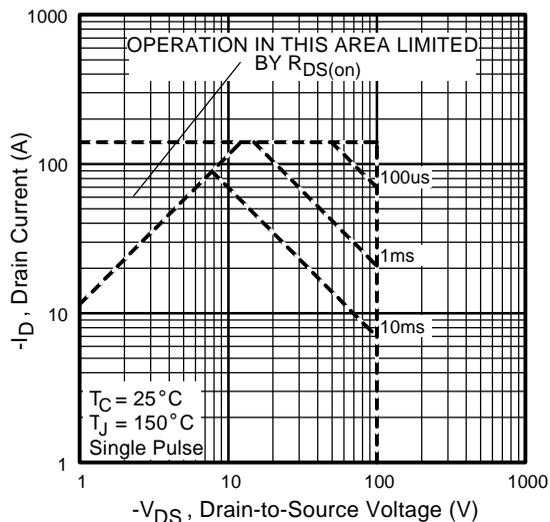


Fig 8. Maximum Safe Operating Area

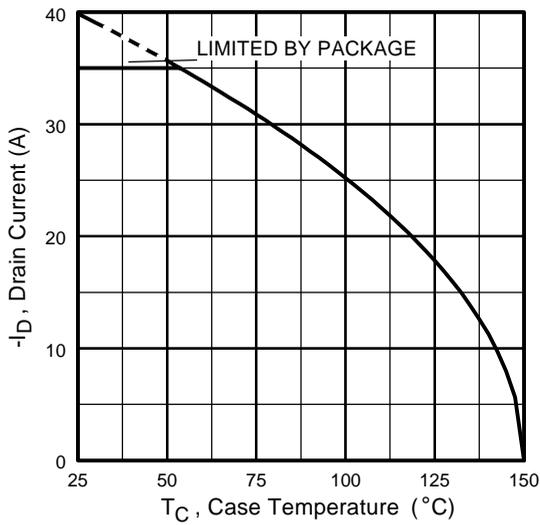


Fig 9. Maximum Drain Current Vs. Case Temperature

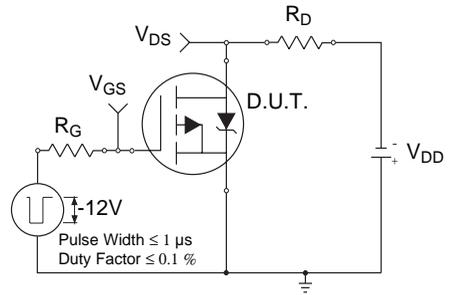


Fig 10a. Switching Time Test Circuit

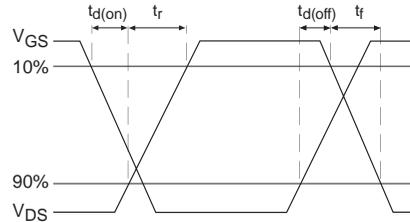


Fig 10b. Switching Time Waveforms

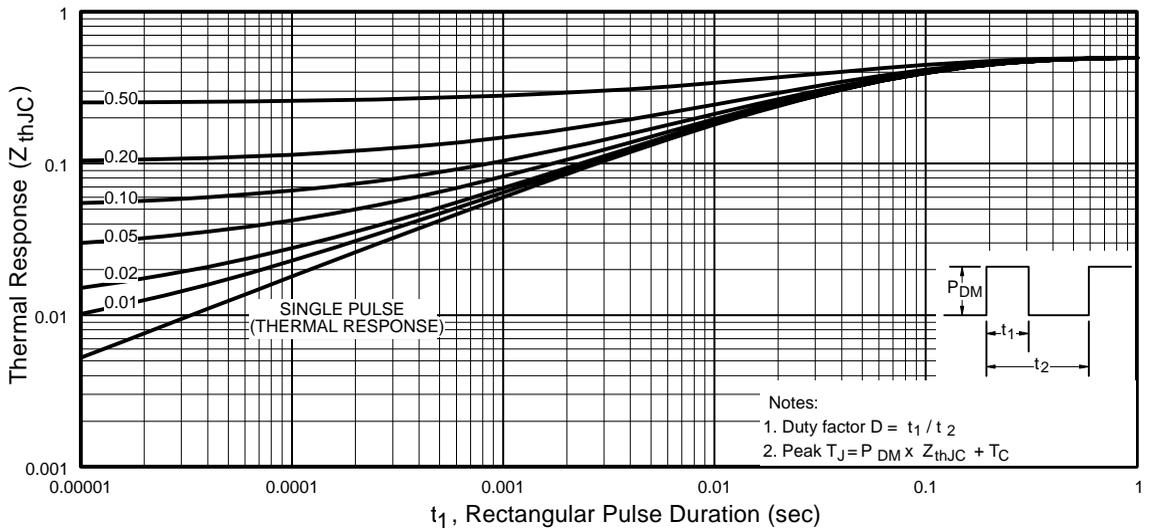


Fig 11. Maximum Effective Transient Thermal Impedance, Junction-to-Case

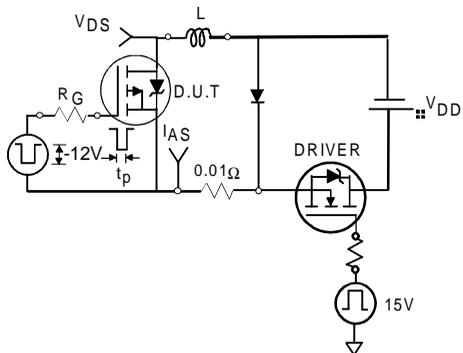


Fig 12a. Unclamped Inductive Test Circuit

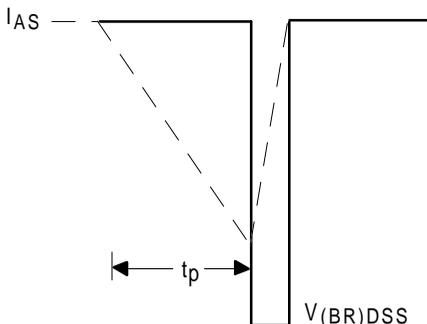


Fig 12b. Unclamped Inductive Waveforms

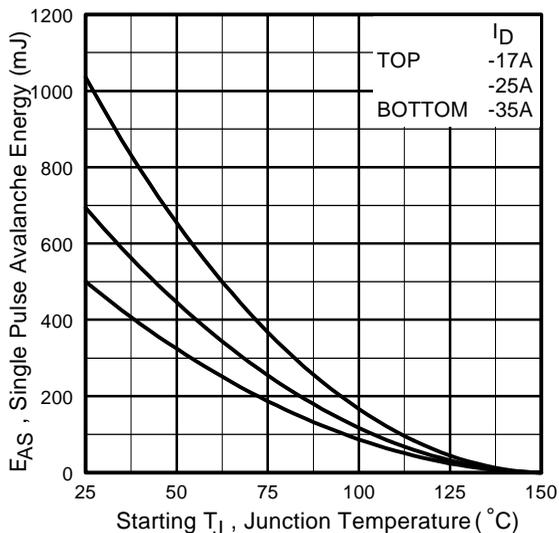


Fig 12c. Maximum Avalanche Energy Vs. Drain Current

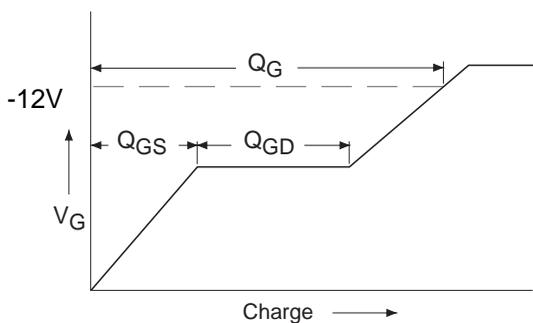


Fig 13a. Basic Gate Charge Waveform

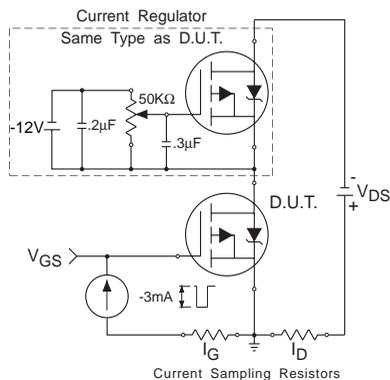
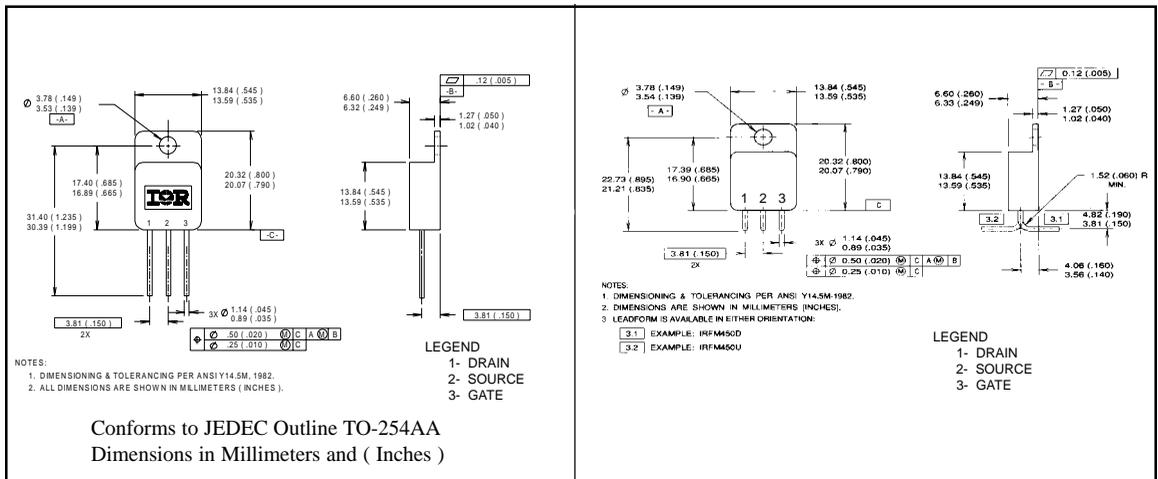


Fig 13b. Gate Charge Test Circuit

- ① Repetitive Rating; Pulse width limited by maximum junction temperature. Refer to current HEXFET reliability report.
- ② @ $V_{DD} = -25V$, Starting $T_J = 25^\circ C$, $EAS = [0.5 * L * (I_L^2)]$
Peak $I_L = -35A$, $V_{GS} = -12V$, $25 \leq R_G \leq \Omega$
- ③ $ISD \leq -35A$, $di/dt \leq -480A/\mu s$,
 $V_{DD} \leq BV_{DSS}$, $T_J \leq 150^\circ C$
Suggested $R_G = 2.35\Omega$
- ④ Pulse width $\leq 300 \mu s$; Duty Cycle $\leq 2\%$
- ⑤ $K/W = ^\circ C/W$
 $W/K = W/^\circ C$

- ⑥ **Total Dose Irradiation with V_{GS} Bias.**
-12 volt V_{GS} applied and $V_{DS} = 0$ during irradiation per MIL-STD-750, method 1019.
- ⑦ **Total Dose Irradiation with V_{DS} Bias.**
 $V_{DS} = 0.8$ rated BV_{DSS} (pre-radiation) applied and $V_{GS} = 0$ during irradiation per MIL-STD-750, method 1019.
- ⑧ This test is performed using a flash x-ray source operated in the e-beam mode (energy ~2.5 MeV), 30 nsec pulse.
- ⑨ Process characterized by independent laboratory.
- ⑩ All Pre-Radiation and Post-Radiation test conditions are **identical** to facilitate direct comparison for circuit applications.

Case Outline and Dimensions — TO-254AA



CAUTION

BERYLLIA WARNING PER MIL-PRF-19500

Package containing beryllia shall not be ground, sandblasted, machined, or have other operations performed on them which will produce beryllia or beryllium dust. Furthermore, beryllium oxide packages shall not be placed in acids that will produce fumes containing beryllium.



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